

Lawrence Berkeley National Laboratory

Advanced Light Source

Title

Electronic structure of monolayer 1T'-MoTe₂ grown by molecular beam epitaxy

Permalink

<https://escholarship.org/uc/item/2vq3964w>

Journal

APL Materials, 6(2)

ISSN

2166-532X

Authors

Tang, Shujie
Zhang, Chaofan
Jia, Chunjing
[et al.](#)

Publication Date

2018-02-01

DOI

10.1063/1.5004700

Peer reviewed

1 **Electronic structure of monolayer 1T'-MoTe₂ grown by molecular**
2 **beam epitaxy**

3
4 Shujie Tang^{1,2,3,4,5}, Chaofan Zhang^{1,2,6,7}, Chunjing Jia^{1,2}, Hyejin Ryu^{3,8},
5 Choongyu Hwang⁹, Makoto Hashimoto¹⁰, Donghui Lu¹⁰, Zhi Liu^{4,5},
6 Thomas P. Devereaux^{1,2}, Zhi-Xun Shen^{1,2*}, Sung-Kwan Mo^{3*}

7 ¹*Stanford Institute for Materials and Energy Sciences, SLAC National Accelerator*
8 *Laboratory, 2575 Sand Hill Road, Menlo Park, California 94025, USA*

9 ²*Geballe Laboratory for Advanced Materials, Departments of Physics and Applied*
10 *Physics, Stanford University, Stanford, California 94305, USA*

11 ³*Advanced Light Source, Lawrence Berkeley National Laboratory, Berkeley,*
12 *California 94720, USA*

13 ⁴*State Key Laboratory of Functional Materials for Informatics, Shanghai Institute of*
14 *Microsystem and Information Technology, Chinese Academy of Sciences, Shanghai*
15 *200050, China*

16 ⁵*School of Physical Science and Technology, Shanghai Tech University, Shanghai*
17 *200031, China*

18 ⁶*College of Optoelectronic Science and Engineering, National University of Defense*
19 *Technology, Changsha 410073, China*

20 ⁷*Interdisciplinary Center of Quantum Information, National University of Defense*
21 *Technology, Changsha 410073, China*

22 ⁸*Max Planck-POSTECH/Hsinchu Center for Complex Phase Materials, Max Plank*
23 *POSTECH/Korea Research Initiative (MPK), Gyeongbuk 37673, Korea*

24 ⁹*Department of Physics, Pusan National University, Busan 46241, Korea*

25 ¹⁰*Stanford Synchrotron Radiation Lightsource, SLAC National Accelerator*

26 *Laboratory, 2575 Sand Hill Road, Menlo Park, California 94025, USA*

27

28 **E-mail: zxshen@stanford.edu, skmo@lbl.gov*

29 **Abstract**

30

31 **Monolayer transition metal dichalcogenides (TMDCs) in 1T' structural phase**
32 **have drawn a great deal of attention due to the prediction of quantum spin Hall**
33 **insulator states. The band inversion and the concomitant changes in the band**
34 **topology induced by the structural distortion from 1T to 1T' phases are well**
35 **established. However, the band gap opening due to the strong spin-orbit coupling**
36 **(SOC) is only verified for 1T'-WTe₂ recently and still debated for other TMDCs.**
37 **Here we report a successful growth of high-quality monolayer 1T'-MoTe₂ on**
38 **bilayer graphene substrate through molecular beam epitaxy. Using in-situ angle-**
39 **resolved photoemission spectroscopy (ARPES), we have investigated the low-**
40 **energy electronic structure and Fermi surface topology. The SOC-induced**
41 **breaking of the band degeneracy points between the valence and conduction bands**
42 **is clearly observed by ARPES. However, the strength of SOC is found to be**
43 **insufficient to open a band gap, which makes monolayer 1T'-MoTe₂ on bilayer**
44 **graphene a semimetal.**

45

46

47 Two-dimensional (2D) transition metal dichalcogenide (TMDC) is a versatile
48 material platform, in which electrical, optical, and topological properties can be
49 controlled through thickness, strain, field, and other perturbations.^{1,2,3,4} The most well-
50 studied example is 2H-MX₂ (M=Mo, W; X=S, Se) semiconductor that makes a
51 transition from indirect band gap to direct band gap only in the monolayer^{4,5}, with well-
52 pronounced spin-splitting^{6,7} and valley degrees of freedom^{8,9}. Other structural phases
53 stemming from different stacking orders between transitional metal and chalcogen
54 layers deliver distinct physical properties even with the same constituent atoms.

55 1T'-MX₂ (M=Mo, W; X=S, Se, Te) has gained particular interest regarding its
56 topological properties. While its three-dimensional bulk form has been explored in
57 terms of type-II Weyl semimetal^{10,11,12,13}, the monolayer is predicted to host quantum
58 spin Hall (QSH) insulator³. QSH insulator, or two-dimensional (2D) topological
59 insulator, is a topologically nontrivial quantum state, which is hallmarked by the helical
60 edge state protected by time reversal symmetry and the bulk (as opposed to the edge)
61 band gap opening due to strong spin-orbit coupling (SOC)^{14,15,16}. The resulting
62 transport properties exhibit quantized Hall conductance even in the absence of magnetic
63 field, and spin-polarized edge current are expected to be useful for the spintronic
64 applications. The QSH phase in 1T' TMDC has been recently realized only in 1T'-
65 WTe₂^{17,18}. It is of great interest whether it is possible to realize a QSH state in other 1T'-
66 TMDCs and whether fundamental parameters such as bulk band gap would be different
67 from those of 1T'-WTe₂.

68 Many efforts have been devoted to achieve a QSH state in monolayer 1T'-MoTe₂.³

69 ^{19,20,21} From the electronic structure point of view, two critical elements of achieving a
70 QSH state in group VI TMDCs are the band inversion caused by the structural distortion
71 from 1T phase to 1T' and the 2D bulk band gap induced by strong SOC.¹⁸ The former
72 has been well established by the previous theoretical calculations.^{3, 19, 20} However, as
73 shown in Table 1, the calculated band gap size varies significantly depending on
74 calculation methods, even to a degree that it is not clear whether 1T'-MoTe₂ is a
75 semiconductor or a semimetal. Optical absorption and transport measurements report a
76 60 meV bulk gap in few layer mechanically exfoliated (ME) 1T'-MoTe₂,²⁰ while CVD-
77 grown monolayer 1T'-MoTe₂ shows a metallic transport behavior.²¹ Whether the SOC
78 is strong enough to open a bulk gap is still not very clear. A characterization tool that
79 can directly visualize the band structure and the size of the band gap, such as angle-
80 resolved photoemission spectroscopy (ARPES)^{22,23}, would provide a clearer insight on
81 this aspect.

82 In this Letter, we report a successful growth of monolayer 1T'-MoTe₂ on bilayer
83 graphene (BLG) substrate using molecular beam epitaxy (MBE). The electronic
84 structure of epitaxial 1T'-MoTe₂ has been investigated by in-situ ARPES. We found
85 that the SOC indeed breaks the band degeneracy points and separates the valence and
86 conduction bands. However, the strength of SOC is not enough to open a 2D bulk band
87 gap, which makes monolayer 1T'-MoTe₂ on BLG a semimetal.

88 Both thin film growth and ARPES characterization of 1T'-MoTe₂ were performed
89 at the Beamline 10.0.1, Advanced Light Source, Lawrence Berkeley National
90 Laboratory. 1T'-MoTe₂ was grown by MBE with a base pressure of $\sim 2 \times 10^{-10}$ Torr. Mo

91 (99.99% purity) and Te (99.999% purity) were evaporated by an e-beam evaporator and
92 a Knudsen cell, respectively, with the flux ratio of $\sim 1:20$. The substrate was BLG
93 prepared by vacuum graphitization of 6H-SiC(0001).²⁴ The substrate temperature was
94 set at 280°C for growth. The flux ratio between Mo and Te was 1:10. The growth rate
95 was 15 minutes per layer. Following the growth, a 20-minute post annealing process at
96 the same temperature was performed. Additional ARPES measurements were
97 performed at the Beamline 5-4, Stanford Synchrotron Radiation Lightsource (SSRL),
98 SLAC National Accelerator Laboratory. The band structure calculation is performed by
99 using generalized gradient approximation method with PBE exchange-correlation
100 functional as implemented in the VASP package²⁵. The lattice constant used is of $a =$
101 6.38 \AA , $b = 3.45 \text{ \AA}$ for 1T'-MoTe₂.

102 The crystal structure of 1T'-MoTe₂ is illustrated in Fig. 1a. It can be seen as a
103 distorted 1T-MoTe₂, for which Mo atoms are in octahedral coordination with Te atoms.
104 With the distortion, Mo atoms shift off the center of Te octahedra toward X direction
105 forming zigzag metal chains along Y direction. The Te atoms also shift accordingly,
106 making two types of Te with inequivalent coordinations. Fig. 1b shows the Brillion
107 zone of 1T'-MoTe₂. The Reflection high-energy electron diffraction (RHEED) patterns
108 before and after the thin film growth are shown in Fig. 1c. The sharp diffraction stripes
109 after growth indicate the high crystalline quality of 1T'-MoTe₂ thin film. The thermal
110 stability of the sample is checked by annealing the sample at 350 °C under Te
111 atmosphere. No obvious change in RHEED pattern was observed, indicating growth
112 temperature 280 °C is far below the decomposing temperature, thus retaining high

113 crystallinity of the sample²⁶. Using lattice constant of BLG $\sim 2.46 \text{ \AA}$ as a reference, one
114 can get the lattice parameter of $1T'$ -MoTe₂ on BLG $\sim 6.3 \text{ \AA}$, which is consistent with
115 reported values³. Fig. 1d is the angle-integrated core level spectrum, clearly showing
116 the characteristic Mo $4p$ peak and Te $4d$ peaks. Figure 2 is the low-energy electron
117 diffraction (LEED) pattern taken with electron kinetic energy of 94 eV to reveal the
118 surface symmetry and lattice structure. The blue solid circles indicate the first-order
119 diffraction from BLG substrate. The six spots surrounding each of them come from
120 $6\sqrt{3}R30^\circ$ superlattice diffractions between graphene and SiC²⁴. Due to the symmetry
121 mismatch between three-fold rotational symmetric BLG and two-fold symmetric $1T'$ -
122 MoTe₂, there are three energetically equivalent rotational alignments between BLG and
123 $1T'$ -MoTe₂²⁷. This results in three sets of reciprocal lattices superposed in both LEED
124 and ARPES data. The LEED pattern from different domains of $1T'$ -MoTe₂ are indicated
125 by the dotted lines with different colors in Fig. 2a. Using the in-plane lattice constant
126 of graphene $a = 2.46 \text{ \AA}$, one can get the lattice constant of $1T'$ -MoTe₂, $a = 6.3 \text{ \AA}$, $b =$
127 3.4 \AA , consistent with the previously reported values³ as well as with that from our
128 RHEED measurement. Fig. 2b shows the superposition of the Brillion zones from three
129 equivalent $1T'$ -MoTe₂ and graphene lattices.

130 Figure 3 show the overall electronic structure and Fermi surface (FS) topology from
131 ARPES measurements on the monolayer $1T'$ -MoTe₂/BLG. Fig. 3a is the FS intensity
132 map, which shows six-fold symmetry due to the superposition of three $1T'$ -MoTe₂
133 domains with 120° rotation with respect to each other. One may extract single-domain
134 FS from the ARPES data as shown in Fig. 3b. There are one hole pocket located at the

135 zone center, two electron pockets along the ΓY direction, and two more electron pockets
136 located at the zone boundaries. The topology of the FS plays a key role in understanding
137 the transport properties of the semimetal in which the hole and electron carriers coexist.
138 Perfect electron-hole compensation is proposed to be responsible for the non-saturating
139 magneto-resistance in three-dimensional bulk $1T'$ - WTe_2 .²⁸ However, too many bands
140 crossing the Fermi energy (E_F) in a confined momentum space have challenged ARPES
141 measurements and interpretations.^{29, 30} The simplified FS in monolayer $1T'$ - $MoTe_2$
142 makes the evaluation easier and reliable. We have obtained concentration ratio between
143 the n and p type carriers $\sim 6:10$. Considering that the volume of electron (hole) pocket
144 increase (decrease) very quickly above the E_F , one may easily achieve the n and p
145 carries balance with slightly doping on the film to realize the electron-hole
146 compensation condition in the monolayer^{1, 31}.

147 Fig. 3c is the overall band structure along the ΓY direction measured by in-situ
148 ARPES, superimposed with the theoretical calculation made with PBE method. Due to
149 the superimposed rotational domains, the signal from the ΓP direction (Fig. 1b) overlaps
150 with that from ΓY direction within a single detection plane. However, the low energy
151 bands from ΓP are contained within the envelop of ΓY bands in both theory and
152 experiment. The domain size of the film is estimated to be tens of nanometer^{1, 18}, which
153 call for further studies with characterization tools with high spatial resolution such as
154 STM and nano-ARPES to disentangle the superposition of signals from domains with
155 different orientations. Overall, the experimental band structure and FS topology from
156 ARPES agree well with the theoretical calculation.

157 Now we focus on the low energy electronic structure right near the E_F . According
158 to theoretical calculations,^{3, 19, 20} the transition from 1T to 1T' inverts the band order
159 leading to a band degeneracy point between the valence and conduction band at Δ point
160 (Fig. 4a, left). The SOC then lift the degeneracy at the cross point (Fig 4b, right) to
161 make the system to be an insulator with a bulk band gap or a semimetal, depending on
162 the strength of the coupling. The low energy band dispersion along both ΓX and ΓY
163 directions (Fig. 4b and c), and corresponding momentum distribution curves (MDCs)
164 and energy distribution curves (EDCs) along the ΓY direction (Fig.4 d and e) clearly
165 indicate well-separated valence and conduction bands confirming the scenario
166 mentioned above. The relatively broad linewidth of EDCs may indicate the possible
167 variation of the gap size from domain to domain due to the much larger ARPES beam
168 spot size than the typical domain size of the sample. Nonetheless, the band structure
169 measured by ARPES clearly exhibit that the hole band at Γ crosses the E_F , while the
170 conduction band minimum locates well below the E_F , leading to a FS with both electron
171 and hole pockets. This shows that monolayer 1T'-MoTe₂ on BLG is a semimetal with
172 a moderate strength of SOC.

173 Considering the weaker SOC in Mo compared to W, in general, one would expect
174 that the SOC-induced energy bandgap in 1T'-MoTe₂ is smaller than that in 1T'-WTe₂.
175 In addition, strain and electron-electron interaction are believed to play important roles
176 in the low energy electronic structure of 1T'-MoTe₂.^{3, 32} As shown in the calculations^{3, 32},
177 size of the gap is very sensitive to the lattice constant. However, a large strain, $\sim 4\sim 6\%$
178 of the lattice constant, is needed to lift the crossover of conduction and valence band

179 and to open the bulk gap. It has been known that van der Waals epitaxy adopted in our
180 growth of 1T'-MoTe₂ on graphene minimize the strain effect caused by lattice
181 mismatch³³. A strong electron-electron correlation, which is largely screened in the bulk
182 1T'-MoTe₂, could also enlarge the separation between the conduction and the valence
183 band³². As calculated in Ref. 32, even with a very strong on-site Coulomb repulsion ~
184 5 eV, the band gap remains closed for 1T'-MoTe₂. In our 1T'-MoTe₂/BLG thin films,
185 the conducting graphene substrate enhances the screening to lower the strength of on-
186 site Coulomb interactions, which would act against the bulk gap opening due to the
187 electron-electron interaction.

188 In summary, high-quality monolayer 1T'-MoTe₂ has been grown on BLG substrate
189 by MBE. In-situ LEED and ARPES measurements are performed to characterize the
190 crystal and electronic structure. It has been shown that three equivalent rotational
191 domains of 1T'-MoTe₂ coexist and contribute to our spectra. The overall electronic
192 structure obtained from ARPES exhibit excellent agreement with theoretical
193 calculations, including the predicted degeneracy lifting induced by SOC. However, the
194 splitting due to the SOC is not large enough to open a 2D bulk gap. The valence band
195 maximum locates above the conduction band minimum resulting in a FS with both
196 electron and hole pockets. Our measurements confirm that the epitaxially-grown
197 monolayer 1T'-MoTe₂ on BLG is a semimetal.

198

199 **Acknowledgments**

200 The ARPES and thin film growth works at the Stanford Institute for Materials and

201 Energy Sciences and Stanford University are supported by the Office of Basic Energy
202 Sciences, Division of Materials Science and AFOSR Grant FA9550-14-1-0277 through
203 the University of Washington that support the ALS activity by the Stanford team.
204 Research performed at ALS (thin film growth and ARPES) is supported by the Office
205 of Basic Energy Sciences, US DOE under Contract No. DE-AC02-05CH11231. SSRL
206 is supported by the Office of Basic Energy Sciences, US DOE under Contract No. DE-
207 AC02-76SF00515. Z. L. is supported by the National Natural Science Foundation of
208 China (11227902). S. T. acknowledges the support by CPSF-CAS Joint Foundation for
209 Excellent Postdoctoral Fellows. H. R. and C. H. acknowledge the support from the NRF,
210 Korea through Max Planck Korea/POSTECH Research Initiative (No. 2011-0031558)
211 and Basic Science Research Program (No. 2015R1C1A1A01053065). A portion of the
212 computational work was performed using the resources of the National Energy
213 Research Scientific Computing Center (NERSC) supported by the US Department of
214 Energy, Office of Science, under Contract No. DE-AC02-05CH11231.

215

216 **References**

217

- 218 1. Zhang Y, Chang T-R, Zhou B, Cui Y-T, Yan H, Liu Z, Schmitt F, Lee J, Moore R, Chen Y,
219 Lin H, Jeng H-T, Mo S-K, Hussain Z, Bansil A, Shen Z-X. Direct observation of the
220 transition from indirect to direct bandgap in atomically thin epitaxial MoSe₂. *Nat*
221 *Nanotech* 2014, **9**(2): 111-115.
- 222
- 223 2. Desai SB, Seol G, Kang JS, Fang H, Battaglia C, Kapadia R, Ager JW, Guo J, Javey A.
224 Strain-Induced Indirect to Direct Bandgap Transition in Multilayer WSe₂. *Nano Lett* 2014,
225 **14**(8): 4592-4597.
- 226
- 227 3. Qian X, Liu J, Fu L, Li J. Quantum spin Hall effect in two-dimensional transition metal
228 dichalcogenides. *Science* 2014, **346**(6215): 1344-1347.

- 229
- 230 4. Mak KF, Lee C, Hone J, Shan J, Heinz TF. Atomically Thin MoS₂: A New Direct-Gap
231 Semiconductor. *Phys Rev Lett* 2010, **105**(13): 136805.
232
- 233 5. Splendiani A, Sun L, Zhang Y, Li T, Kim J, Chim C-Y, Galli G, Wang F. Emerging
234 Photoluminescence in Monolayer MoS₂. *Nano Lett* 2010, **10**(4): 1271-1275.
235
- 236 6. Riley JM, Mazzola F, Dendzik M, Michiardi M, Takayama T, Bawden L, Granerod C,
237 Leandersson M, Balasubramanian T, Hoesch M, Kim TK, Takagi H, Meevasana W,
238 Hofmann P, Bahramy MS, Wells JW, King PDC. Direct observation of spin-polarized bulk
239 bands in an inversion-symmetric semiconductor. *Nat Phys* 2014, **10**(11): 835-839.
240
- 241 7. Mo S-K, Hwang C, Zhang Y, Fanciulli M, Muff S, Dil JH, Shen Z-X, Hussain Z. Spin-
242 resolved photoemission study of epitaxially grown MoSe₂ and WSe₂ thin films. *J Phys*
243 *Condens Matter* 2016, **28**(45): 454001.
244
- 245 8. Mak KF, He K, Shan J, Heinz TF. Control of valley polarization in monolayer MoS₂ by
246 optical helicity. *Nat Nanotech* 2012, **7**(8): 494-498.
247
- 248 9. Mak KF, McGill KL, Park J, McEuen PL. The valley Hall effect in MoS₂ transistors. *Science*
249 2014, **344**(6191): 1489-1492.
250
- 251 10. Deng K, Wan G, Deng P, Zhang K, Ding S, Wang E, Yan M, Huang H, Zhang H, Xu Z,
252 Denlinger J, Fedorov A, Yang H, Duan W, Yao H, Wu Y, Fan S, Zhang H, Chen X, Zhou S.
253 Experimental observation of topological Fermi arcs in type-II Weyl semimetal MoTe₂.
254 *Nat Phys* 2016, **12**(12): 1105-1110.
255
- 256 11. Tamai A, Wu QS, Cucchi I, Bruno FY, Riccò S, Kim TK, Hoesch M, Barreteau C, Giannini E,
257 Besnard C, Soluyanov AA, Baumberger F. Fermi Arcs and Their Topological Character in
258 the Candidate Type-II Weyl Semimetal MoTe₂. *Phys Rev X* 2016, **6**(3): 031021.
259
- 260 12. Sun Y, Wu S-C, Ali MN, Felser C, Yan B. Prediction of Weyl semimetal in orthorhombic
261 MoTe₂. *Phys Rev B* 2015, **92**(16): 161107.
262
- 263 13. Jiang J, Liu ZK, Sun Y, Yang HF, Rajamathi CR, Qi YP, Yang LX, Chen C, Peng H, Hwang
264 CC, Sun SZ, Mo SK, Vobornik I, Fujii J, Parkin SSP, Felser C, Yan BH, Chen YL. Signature of
265 type-II Weyl semimetal phase in MoTe₂. *Nature communication* 2017, **8**: 13973.
266
- 267 14. Murakami S. Quantum Spin Hall Effect and Enhanced Magnetic Response by Spin-Orbit
268 Coupling. *Phys Rev Lett* 2006, **97**(23): 236805.
269
- 270 15. Bernevig BA, Hughes TL, Zhang S-C. Quantum Spin Hall Effect and Topological Phase
271 Transition in HgTe Quantum Wells. *Science* 2006, **314**(5806): 1757-1761.
272

- 273 16. Kane CL, Mele EJ. Quantum Spin Hall Effect in Graphene. *Phys Rev Lett* 2005, **95**(22):
274 226801.
- 275
- 276 17. Fei Z, Palomaki T, Wu S, Zhao W, Cai X, Sun B, Nguyen P, Finney J, Xu X, Cobden DH.
277 Edge conduction in monolayer WTe_2 . *Nat Phys* 2017, **13**(7): 677-682.
- 278
- 279 18. Tang S, Zhang C, Wong D, Pedramrazi Z, Tsai H-Z, Jia C, Moritz B, Claassen M, Ryu H,
280 Kahn S, Jiang J, Yan H, Hashimoto M, Lu D, Moore RG, Hwang C-C, Hwang C, Hussain Z,
281 Chen Y, Ugeda MM, Liu Z, Xie X, Devereaux TP, Crommie MF, Mo S-K, Shen Z-X.
282 Quantum spin Hall state in monolayer $1T'$ - WTe_2 . *Nat Phys* 2017, **13**(7): 683-687.
- 283
- 284 19. Choe D-H, Sung H-J, Chang KJ. Understanding topological phase transition in
285 monolayer transition metal dichalcogenides. *Phys Rev B* 2016, **93**(12): 125109.
- 286
- 287 20. Keum DH, Cho S, Kim JH, Choe D-H, Sung H-J, Kan M, Kang H, Hwang J-Y, Kim SW,
288 Yang H, Chang KJ, Lee YH. Bandgap opening in few-layered monoclinic $MoTe_2$. *Nat*
289 *Phys* 2015, **11**(6): 482-486.
- 290
- 291 21. Naylor CH, Parkin WM, Ping J, Gao Z, Zhou YR, Kim Y, Streller F, Carpick RW, Rappe AM,
292 Drndić M, Kikkawa JM, Johnson ATC. Monolayer Single-Crystal $1T'$ - $MoTe_2$ Grown by
293 Chemical Vapor Deposition Exhibits Weak Antilocalization Effect. *Nano Lett* 2016, **16**(7):
294 4297-4304.
- 295
- 296 22. Damascelli A, Hussain Z, Shen Z-X. Angle-resolved photoemission studies of the
297 cuprate superconductors. *Rev Mod Phys* 2003, **75**(2): 473-541.
- 298
- 299 23. Mo S-K. Angle-resolved photoemission spectroscopy for the study of two-dimensional
300 materials. *Nano Convergence* 2017, **4**(1): 6.
- 301
- 302 24. Qingyan W, Wenhao Z, Lili W, Ke H, Xucun M, Qikun X. Large-scale uniform bilayer
303 graphene prepared by vacuum graphitization of $6H$ - $SiC(0001)$ substrates. *J Phys*
304 *Condens Matter* 2013, **25**(9): 095002.
- 305
- 306 25. Kresse G, Furthmüller J. Efficient iterative schemes for ab initio total-energy calculations
307 using a plane-wave basis set. *Phys Rev B* 1996, **54**(16): 11169-11186.
- 308
- 309 26. Choi BK, Kim M, Jung K-H, Kim J, Yu K-S, Chang YJ. Temperature dependence of band
310 gap in $MoSe_2$ grown by molecular beam epitaxy. *Nanoscale Research Letters* 2017,
311 **12**(1): 492.
- 312
- 313 27. Wang E, Ding H, Fedorov AV, Yao W, Li Z, Lv Y-F, Zhao K, Zhang L-G, Xu Z, Schneeloch
314 J, Zhong R, Ji S-H, Wang L, He K, Ma X, Gu G, Yao H, Xue Q-K, Chen X, Zhou S. Fully
315 gapped topological surface states in Bi_2Se_3 films induced by a d-wave high-temperature
316 superconductor. *Nat Phys* 2013, **9**(10): 621-625.

317
318 28. Ali MN, Xiong J, Flynn S, Tao J, Gibson QD, Schoop LM, Liang T, Haldolaarachchige N,
319 Hirschberger M, Ong NP, Cava RJ. Large, non-saturating magnetoresistance in WTe_2 .
320 *Nature* 2014, **514**(7521): 205-208.
321
322 29. Thirupathaiah S, Jha R, Pal B, Matias JS, Das PK, Sivakumar PK, Vobornik I, Plumb NC, Shi
323 M, Ribeiro RA, Sarma DD. $MoTe_2$: An uncompensated semimetal with extremely large
324 magnetoresistance. *Phys Rev B* 2017, **95**(24): 241105.
325
326 30. Chen-Lu W, Yan Z, Jian-Wei H, Guo-Dong L, Ai-Ji L, Yu-Xiao Z, Bing S, Jing L, Cheng H,
327 Ying D, De-Fa L, Yong H, Shao-Long H, Lin Z, Li Y, Jin H, Jiang W, Zhi-Qiang M, You-
328 Guo S, Xiao-Wen J, Feng-Feng Z, Shen-Jin Z, Feng Y, Zhi-Min W, Qin-Jun P, Zu-Yan X,
329 Chuang-Tian C, Xing-Jiang Z. Evidence of Electron-Hole Imbalance in WTe_2 from High-
330 Resolution Angle-Resolved Photoemission Spectroscopy. *Chinese Physics Letters* 2017,
331 **34**(9): 097305.
332
333 31. Kang M, Kim B, Ryu SH, Jung SW, Kim J, Moreschini L, Jozwiak C, Rotenberg E, Bostwick
334 A, Kim KS. Universal Mechanism of Band-Gap Engineering in Transition-Metal
335 Dichalcogenides. *Nano Lett* 2017, **17**(3): 1610-1615.
336
337 32. Kim H-J, Kang S-H, Hamada I, Son Y-W. Origins of the structural phase transitions in
338 $MoTe_2$ and WTe_2 . *Phys Rev B* 2017, **95**(18): 180101.
339
340 33. Novoselov KS, Mishchenko A, Carvalho A, Castro Neto AH. 2D materials and van der
341 Waals heterostructures. *Science* 2016, **353**(6298).
342
343
344

345

346

347 **Table1. Gap size derived from different calculation methods and experimental**

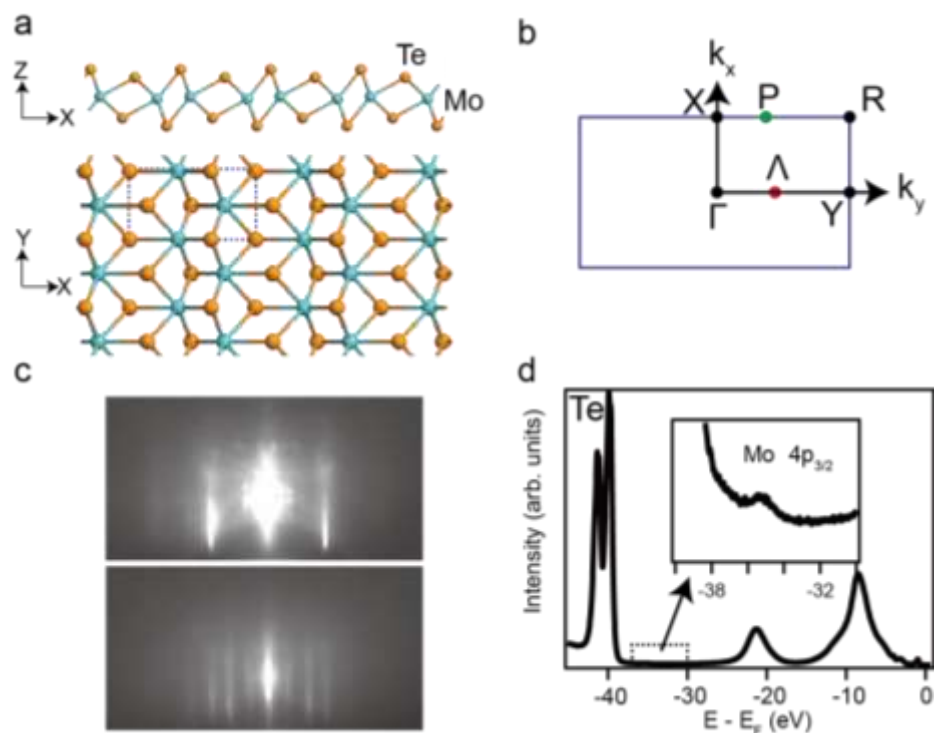
348 **measurements**

349

Calculation or experiment method	Sample fabrication method & thickness	Gap size (eV)	Bulk Conductivity	reference
PBE	--	-0.262	Metallic	Ref. 3
G_0W_0	--	-0.300	Metallic	Ref. 3
PBE+HSE06	--	0.03	semiconductor	Ref. 20
transport	CVD monolayer	--	Metallic	Ref. 21
Optical absorption	ME few layer	0.06	semiconductor	Ref. 20
ARPES	MBE monolayer	--	Metallic	This work

350

351

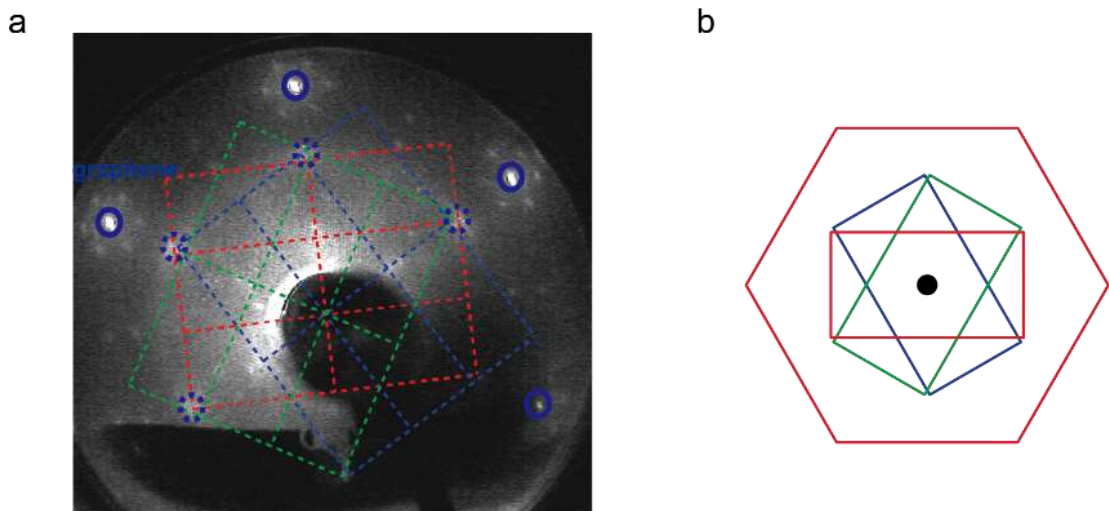


353

354

355 **Fig. 1. MBE growth of 1T'-MoTe₂** (a) Crystal structure of 1T'-MoTe₂, side view
 356 (upper panel) and top view (lower panel). (b) Brillouin Zone of 1T'-MoTe₂. (c)
 357 RHEED patterns of graphene substrate (top) and after monolayer 1T'-MoTe₂ film
 358 growth (bottom). (d) Core level spectrum of 1T'-MoTe₂ thin film, the inset is the
 359 zoom-in of the boxed part.

360



362

363

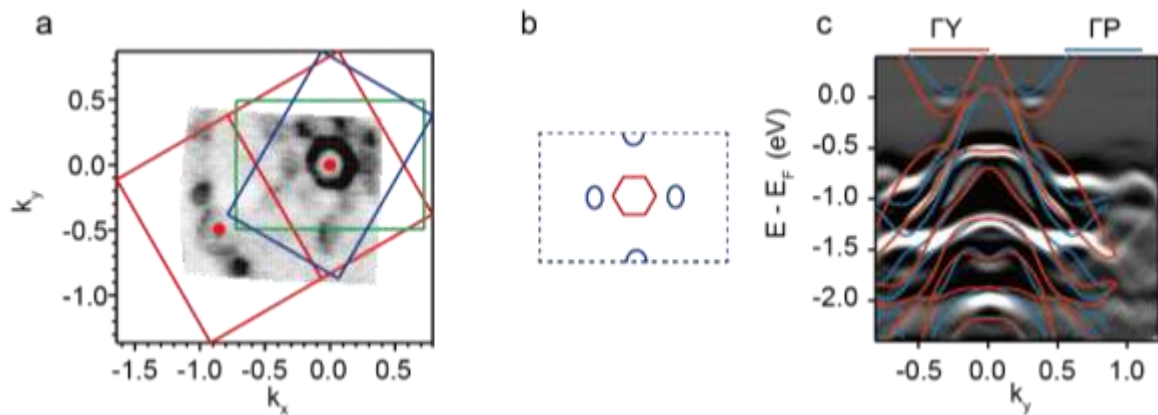
364 **Fig. 2. LEED pattern of 1T'-MoTe₂ film.** (a) LEED pattern (94 eV) of the film. Blue

365 solid circles are the first-order reflection from graphene. The blue dotted circles

366 indicate the reflections from 1T'-MoTe₂. (b) Superposition of the Brillion zones of

367 1T'-MoTe₂ (blue, green, and red rectangles) and BLG (red hexagon).

368



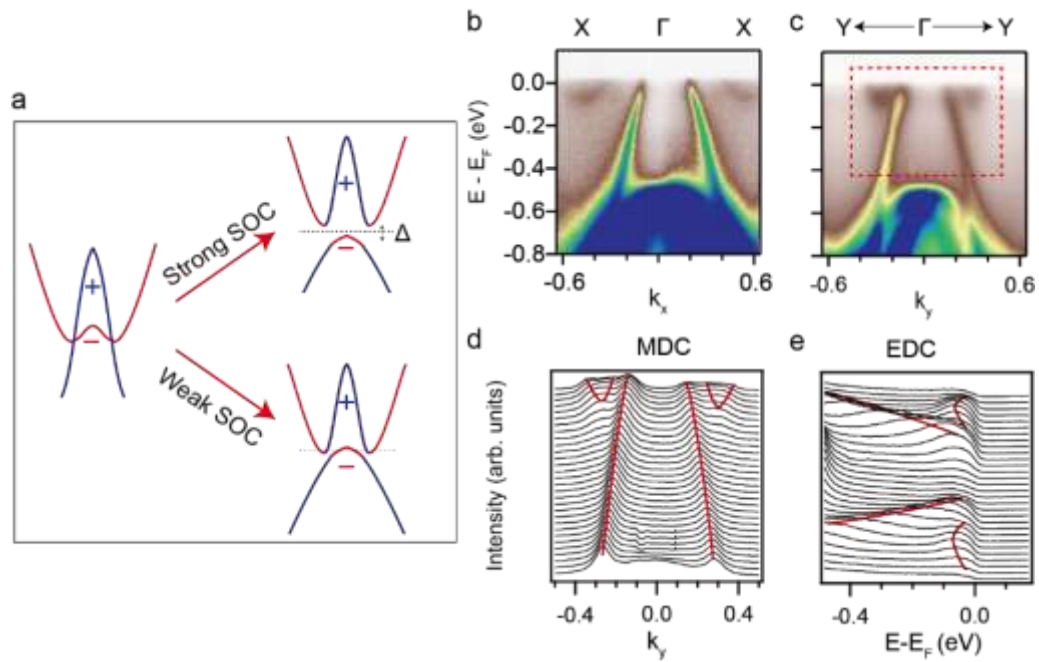
370

371

372 **Fig. 3. Electronic structure of monolayer 1T'-MoTe₂.** (a) Fermi surface intensity
 373 map from ARPES measurement of monolayer 1T'-MoTe₂. The intensity is integrated
 374 within a ± 10 meV window around the Fermi energy. The red, blue and green
 375 rectangles indicate three Brillion Zones from three rotational domains, 120 degrees
 376 with respect to each other. (b) Fermi surface topology extracted from ARPES data for
 377 a single domain. The red and blue pockets represent the hole and electron pockets,
 378 respectively. (c) The second derivative of ARPES spectrum along ΓY superposed with
 379 PBE calculation. The red and blue lines are calculated bands along the ΓY and ΓP
 380 directions, respectively.

381

382



384

385

Fig. 4. Detailed view of low-energy electronic structure of monolayer 1T'-MoTe₂.

386

(a) The band evolution of 1T'-TMDCs under strong and weak SOC. (b, c) Detailed

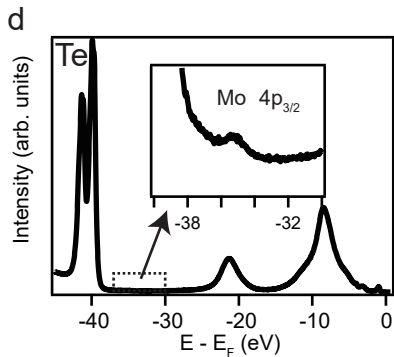
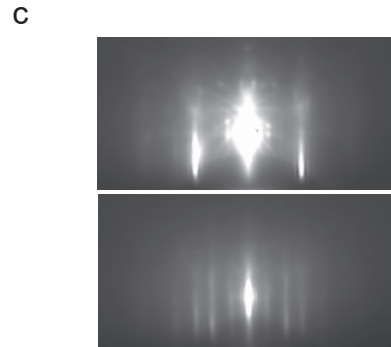
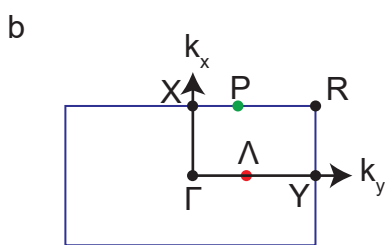
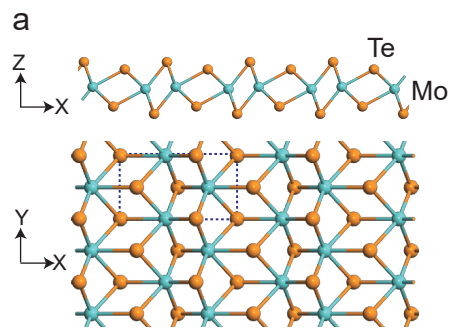
387

ARPES spectra along the Γ X and Γ Y directions, respectively. (d, e) MDCs and EDCs

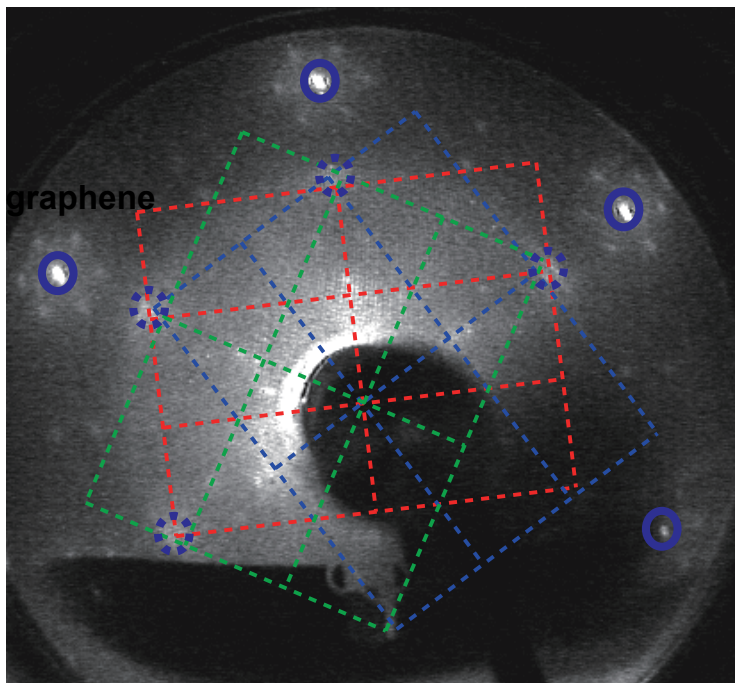
388

along the Γ Y direction corresponding to the boxed area in c.

389



a



b

